

Abstract Submitted  
for the MAR13 Meeting of  
The American Physical Society

**Increase of Structural Phase Transition Temperature with Cr doping in Cr:VO<sub>2</sub> Thin Films** B.L. BROWN, MARK LEE, University of Texas at Dallas, P. CLEM, C.D. NORDQUIST, T.S. JORDAN, S.L. WOLFLEY, D. LEONHARDT, Sandia, J.A. CUSTER, SSA — Bulk crystal VO<sub>2</sub> has a well-known structural phase transition near  $T_c = 68$  °C that separates a low-temperature insulating phase from a high-temperature metallic phase with several orders-of-magnitude resistance contrast between the two phases. We report electrical and optical studies of the effect of Cr doping on the  $T_c$  in Cr:VO<sub>2</sub> thin films. Resistivity, Hall effect, and infrared reflectivity all show that Cr doping systematically increases  $T_c$  from 50 °C up to  $\sim 75$  °C at 11% Cr with similar transition width and hysteresis from DC to infrared, but the effect appears to saturate. At the same time, there is a modest decrease in resistance contrast. We will discuss possible effects of both carrier density and scattering changes across  $T_c$  on the resistance. Sandia National Laboratories is a multi-program laboratory managed and operated by Sandia Corporation, a wholly owned subsidiary of Lockheed Martin Corporation, for the U.S. Department of Energy's National Nuclear Security Administration under contract DE-AC04-94AL85000.

B. L. Brown  
University of Texas at Dallas

Date submitted: 13 Nov 2012

Electronic form version 1.4